

## **AMENDMENTS TO THE CLAIMS**

The following listing of claims will replace all prior versions and listings of claims in the application.

### **LISTING OF CLAIMS**

1. (Currently Amended) A manufacturing method for an electrooptic device that includes a plurality of pixels, a reflecting section that reflects light, and a transmitting section provided in the pixel that allows light to pass therethrough, the manufacturing method comprising the step of:

forming a reflective layer at the reflecting section; and

forming a colored layer that overlaps ~~is overlapping~~ the reflective layer in the pixel, the colored layer is exposed using a mask<sub>1</sub>; ~~wherein~~ the colored layer has an opening with ~~that has~~ a two-dimensional shape having no corner and is formed at ~~corresponding to~~ the reflecting section~~[[,]]~~ in ~~each of~~ at least some of the pixels<sub>1</sub>; ~~wherein~~ the mask has a pattern having ~~[[a]]~~ an asymmetrical, two-dimensional shape with no corner.

2. – 3. (Cancelled)

4. (Currently Amended) A manufacturing method for an electrooptic device that includes a plurality of pixels, a reflecting section that reflects light, and a transmitting section provided in the pixel that allows light to pass therethrough, the manufacturing method comprising the step of:

forming a reflective layer at the reflecting section; and

forming a colored layer that is overlapping the reflective layer in the pixel, the colored layer is exposed using a mask;

~~wherein~~ the colored layer has an opening that has a polygonal two-dimensional shape with ~~and that has~~ all interior angles larger than 90 degrees, the colored layer is formed at ~~corresponding to~~ the reflecting section[[,]] in each of at least some of the pixels;

~~wherein~~ the mask has a pattern that has a polygonal two-dimensional shape that is asymmetrical and has all interior angles larger than 90 degrees.

5. (Cancelled)

6. (Cancelled)

7. (Currently Amended) A manufacturing method for an electrooptic device that includes a plurality of pixels, a reflecting section that reflects light, and a transmitting section provided in the pixel that allows light to pass therethrough, the manufacturing method comprising the step of:

forming a reflective layer at the reflecting section; and

forming a colored layer that is overlapping the reflective layer in the pixel, the colored layer is exposed using a mask;

~~wherein~~ the colored layer has an opening that is formed at ~~in the colored layer corresponding to~~ the reflecting section in each of at least some of the pixels, the opening has a shape such that the positions of intersections of respective normals to two arbitrary tangents on an outer periphery of the opening disperse;

~~wherein~~ the mask has a pattern with an asymmetrical two-dimensional shape such that points of intersection of respective normals to two arbitrary tangents on an outer periphery of the opening are dispersed.

8. – 11. (Cancelled)

12. (Previously Presented) An electronic device, comprising:  
an electrooptic device manufactured by the manufacturing method for an electrooptic device as recited in Claim 1; and  
a control means for controlling the electrooptic device.

13. (Currently Amended) An electrooptic device, comprising:  
a plurality of pixels;  
a reflecting section that reflects light and a transmitting section that allows light to pass therethrough provided in the pixel;  
a reflective layer formed at the reflecting section; and  
a colored layer overlapping the reflective layer in the pixel, the colored layer is exposed using a mask;  
~~wherein, in each of at least some of the pixels, the colored layer formed at~~  
~~corresponding to the reflecting section has an opening; and~~  
~~wherein the opening has [[a]] an asymmetrical, two-dimensional shape~~  
~~with having no corner and the opening has an asymmetrical two-dimensional shape;~~  
~~and~~  
~~wherein the mask has a pattern having [[a]] an asymmetrical, two-~~  
dimensional shape with no corner.

14. (Currently Amended) A manufacturing method for an electrooptic device that includes a plurality of pixels and a reflecting section that reflects light and a

transmitting section that allows light to pass therethrough provided in the pixel, the manufacturing method comprising the steps ~~step~~ of:

forming a reflective layer at the reflecting section; and

forming a colored layer by exposing the colored layer using a mask;

~~wherein~~ the colored layer overlaps the reflective layer in the pixel and the colored layer has an opening; and

~~wherein~~ the mask has a pattern with having ~~[[a]]~~ an asymmetrical, two-dimensional shape with no corner ~~and the pattern has an asymmetrical two-dimensional shape.~~

15. – 17. (Cancelled)